Walk-in interview for the post of JRF

Indian nationals desirous of joining for the post of DST funded research project entitled “Site specific growth and nanomanufacturing of aligned carbon nanotube for device applications” may walk-in on 19th March 2016 with originals of their certificates and testimonials. This is an excellent opportunity to work in frontier areas of CVD growth and electron lithography to fabricate nanoscale devices using aligned CNTs. The applicants must e-mail their applications to viswa@iitmandi.ac.in and must confirm their attendance in advance.

Qualification: M.Tech in Mechanical/Materials/Electrical/Nanotechnology or M.Sc in Physics/Materials Science or other relevant scientific disciplines with at least 55% marks. Having relevant research experience or M.Tech. in relevant disciplines or having qualified NET/ GATE is desirable.

Age: Maximum 28 years on 01.03.2016 (relaxable up to 5 years for SC/ST candidates and 3 years for candidates belonging to OBC)

Salary: Rs. 25,000/- p.m. (subject to fulfilling eligibility criteria).

Duration: The appointment will be made initially for a period of one year, but the tenure may be extended on satisfactory performance up to 3 years. The appointment is co-terminus with the project. The selected candidate will have to join immediately.

Additional information: The position may be converted to a full time Ph. D. position subject to fulfilling eligibility criteria and satisfactory performance.

PI: Dr. Viswanath Balakrishnan, Assistant Professor, School of Engineering
http://faculty.iitmandi.ac.in/~viswa/
https://scholar.google.co.in/citations?user=0GIW2ZYAAAJ&hl=en

Details of the interview

Date: 19.03.2016 (Saturday) Time: 9.30 AM
Venue: Conference Room, Administrative Block (Mandav Building, Mandi Campus), IIT Mandi, Mandi-175001.
How to Reach: http://www.iitmandi.ac.in/institute/howtoreach.html
Contacts: viswa@iitmandi.ac.in